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RADIATION HARDNESS of scDIAMOND DETECTORS under IRRADIATION by MeV energy range CARBON ions (and protons)

# 1. RBI – FACILITIES - accelerators





# 1. RBI – FACILITIES – beam lines



# **1. RBI - FACILITIES - Heavy ion microprobe**



up to 15 MeV (ME/q2) magnetic rigidity.

With short image distance (110 mm) of the new chamber, demagnifications of Dx=90 and Dy=110 12 MeV C



best resolution - 250 nm





### **1. HEAVY IONS - Unique properties** wide range of dE/dx



Electronic stopping power dominates for ions at MeV energies, Bragg peak!

Huge energy transfer (in particular for heavy ions at ~ 1MeV/amu)



### **RBI** accelerators: Terminal voltages – 0.1 to 6 MV lon sources – sputtering, RF alphatross, duoplasmatron

wide range of ranges

Good selection of ion ranges !!

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Silicon	I 127-	Si 28	C 12	He 4	H 1
Range(µm) E=1 MeV	0.37	1.13	1.6	3.5	16.3
Range (µm) E=10 MeV	3.7	4.8	9.5	69.7	709



# **2. RADIATION INDUCED DEFECTS – IBIC**

### ION BEAM INDUCED CHARGE



IBIC - single ion technique for imaging of microscopic distribution of charge transport properties !
Imaging of grain boundaries, defects (such as dislocations), electric field (polarization),...

CVD diamond (1997)





### 2. RADIATION INDUCED DEFECTS – IBIC





 $\frac{Q_0}{O} = 1 + K_{ed} \cdot \text{ONIEL}_{ave}$  $D_d$ 

 $K_{ed}$  –equivalent damage factor (g/MeV) (property of the material + ? )

 $\Phi$ - damaging ion fluence (cm<sup>-2</sup>) NIEL – non ionizing energy loss (MeVcm<sup>2</sup>g<sup>-1</sup>)

 $D_d$  - displacement damage dose ( $\Phi^*NIEL_{ave.}$ )



## 2. RADIATION INDUCED DEFECTS – IBIC





- damaging profile NIEL
- IBIC probe (dE/dx)<sub>el.</sub>









### **3. RADIATION HARDNESS of Si pin diode** Microbeam irradiation protocol





### **3. RADIATION HARDNESS of Si pin diode** MeV ions produce inhomogenoeus damage

In order to compare influence of ion mass/charge on the CCE, damege was produced by different ions of the same depth range in silicon (5  $\mu$ m)

lon	NIEL <sub>ave</sub>
430 keV H	0.87
1.4 MeV He	9.13
2.15 MeV Li	21.91
4 MeV O	129.19
11 MeV CI	450.38**





### **3. RADIATION HARDNESS of Si pin diode** He IBIC probe

1.4 MeV He ions for IBIC have homogeneous e-h pair creation depth profile !  $\frac{Q_0}{Q} = 1$   $\cdot \Phi \cdot NIEL_{ave} \begin{cases} K_{ed} \text{ is the equivalent damage} \\ \text{factor- reflects properties of} \\ \text{material !} \end{cases}$ 





### **3. RADIATION HARDNESS of Si pin diode** MeV ions produce inhomogenoeus damage





### **3. RADIATION HARDNESS of Si pin diode Conclusions of importance to diamond**

- Weak correlation between  $k\sigma$  values and Z of ion
- NIEL scaling works well

Direct comparisson of Si pin diode with scDiamond detector using same range of ions in Si and diamond!

- 1 mm<sup>2</sup>; 500  $\mu$ m thickness Diamond Detectors Ltd.
- 10 mm2; 50 µm thickness Diamond Detectors Ltd.

	Si	Diamond	SiC	Range
Damaging C ions	2.6 MeV	6.5 MeV	4.5 MeV	3 µm
Shallow probe	600 keV He ions	430 keV p	1 MeV He ions	2.25 µm
Deep probe	1.3 MeV p	2 MeV p	1.7 MeV p	25 µm



### **4. RADIATION HARDNESS OF DIAMOND**

### Radiation hardness - experiment and modeling





Problem: increased sesitivity for Si pin diode due to changes in electric field profile



### 4. RADIATION HARDNESS OF DIAMOND Spectroscopic properties





# 4. RADIATION HARDNESS OF DIAMOND

### Radiation hardness - Si vs. Diamond



scCVD (1x1x0.5 mm) and Si pin diode (1 x 0.1 mm)
 50x50 µm<sup>2</sup> areas irradiated with 6.5 MeV C<sup>3+</sup>

- > JDIO imposed dama with 420 kg/( protono
- IBIC images done with 430 keV protons



# 4. RADIATION HARDNESS OF DIAMOND

### Radiation hardness - Si vs. Diamond



Si & diamond irradiated by 6.5 MeV C ions





### 4. RADIATION HARDNESS OF DIAMOND Radiation hardness - Si vs. Diamond



Si irradiated by 2.6 MeV C ions Diamond irradiated by 6.5 MeV C ions





# **4. RADIATION HARDNESS OF DIAMOND**

### Radiation hardness - Si vs. Diamond



6.5 MeV C probe introduce 15 times more charge than 430 keV protons in the same volume – possible polarisation, but not significant!



### 4. RADIATION HARDNESS OF DIAMOND Radiation hardness - Si vs. Diamond



'new' measurements performed one year after 'old'

There is no significant difference due to long term anealing or polarisation



### 4. RADIATION HARDNESS OF DIAMOND Conclusions

In the case of irradiation by 6.5 MeV C ions, induced defects in diamond are affecting CCE more than in Si pin diode!

Higher defect recombination probability (room temperature anealing) in silicon may be one of the main reasons for that.



Other issues:

- Polarization ?
- Priming?
- short ion range strong influence of contact and surface imperfections

4.5 MeV protons,  $(dE/dx)_{nucl}$  = 4.04 10<sup>-5</sup> MeV/mg cm<sup>-2</sup>

3 MeV protons,  $(dE/dx)_{nucl}$  = 5.9 10<sup>-5</sup> MeV/mg cm<sup>-2</sup>



**Initial distribution of** vacancies in  $(1\mu m)^3$ 

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3 MeV protons,  $(dE/dx)_{nucl}$  = 5.9 10<sup>-5</sup> MeV/mg cm<sup>-2</sup>

4.5 MeV protons are producing homogeneous distribution of damage

Spectroscopic performance; 2 MeV protons: < 1% energy resolution Can cope with 10000 cps in 50 x 50  $\mu$ m<sup>2</sup> !











Total fluence 2  $10^7$  protons Area 50 x 50  $\mu$ m<sup>2</sup>











Diamond Detectors -Development and Applications, 2<sup>nd</sup> RBI Detector Workshop, 7-10 May 2012, Plitvice Lakes National Park, Croatia



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